

Notice of References Cited	Application/Control No. 10/705,254		Applicant(s)/Patent Under Reexamination CAMPAGNOLA ET AL.	
	Examiner Cynthia Hamilton		Art Unit 1752	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-4,197,133	04-1980	Zweifel et al.	430/197
*	B	US-4,424,325	01-1984	Tsunoda et al.	430/195
*	C	US-5,518,864	05-1996	Oba et al.	430/325
*	D	US-4,433,043	02-1984	Sawada et al.	430/175
*	E	US-3,265,772	08-1966	STANLEY TOCKER	522/109
*	F	US-4,602,097	07-1986	Curtis, John R.	522/36
*	G	US-2003/0194715	10-2003	Li et al.	435/6
*	H	US-5,637,460	06-1997	Swan et al.	435/6
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	WO 97/07161 A1	02-1997	World Intellect	STARK et al.	
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Vincent D. McGinniss, "Radiation Curing", pages 1-25 from Kirk -Othmer Encyclopedia of Chemical Technology (posted online December 4, 2000 on www.mrw.interscience.wiley. com, copyrighted by John Wiley & Sons, Inc in 1996.
	V	Thompson et al, eds , Introduction to Microlithography, Second Edition, ACS Professional Reference Book, American Chemical Society, Washington, DC 1994 pages 162-165.
	W	Cao et al, "Synthesis of Diazo-resin and its Photocrosslinking Reaction", Polymer International, vol. 45 , 1998, pages 142-146 (no month given).
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.